

## IN THE CLAIMS

Please cancel claim 1 and add new claims 33-63.

### Listing of Claims:

Claims 1-32 (Canceled)

33. (New) An information recording medium comprising a first information layer and a second information layer,

wherein the first information layer comprises a first recording layer in which a reversible phase change is caused between a crystalline phase and an amorphous phase by irradiation of a laser beam or Joule heat generated by application of current,

the second information layer comprises a second recording layer in which a reversible phase change is caused between a crystalline phase and an amorphous phase by the irradiation of the laser beam or the Joule heat generated by the application of the current,

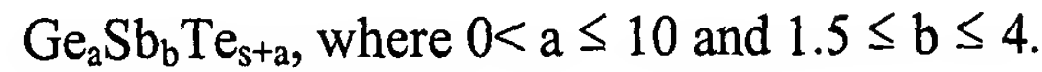
wherein the first material comprises Ge, Sb, and Te,

the second material comprises Sb and at least one element M1 selected from the group consisting of Ag, In, Ge, Sn, Se, Bi, Au, Mn and Te,

the first information layer is disposed closer to a side from which the laser beam is incident than the second information layer, and

wherein a separating layer is provided to distinguish the first recording layer and the second recording layer, the thickness of the separating layer is in the range of 1  $\mu\text{m}$  to 50  $\mu\text{m}$ .

34. (New) The information recording medium according to claim 1, wherein the first material is represented by a composition formula:



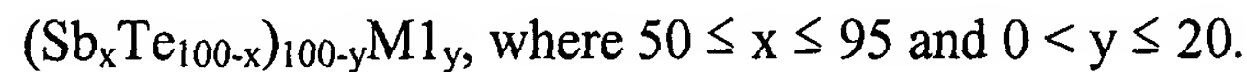
35. (New) The information recording medium according to claim 1, wherein the first material is represented by a composition formula:

$(\text{Ge-M2})_a\text{Sb}_b\text{Te}_{3+a}$ , where M2 is at least one element selected from the group consisting of Sn and Pb, and  $0 < a \leq 10$  and  $1.5 \leq b \leq 4$ .

36. (New) The information recording medium according to claim 1, wherein the first material is represented by a composition formula:

$(\text{Ge}_a\text{Sb}_b\text{Te}_{3+a})_{100-c}\text{M3}_c$ , where M3 is at least one element selected from the group consisting of Si, Ti, V, Cr, Mn, Fe, Co, Ni, Cu, Se, Zr, Nb, Mo, Ru, Rh, Pd, Ag, In, Sn, Ta, W, Os, Ir, Pt, Au and Bi, and  $0 < a \leq 10$ ,  $1.5 \leq b \leq 4$ , and  $0 < c \leq 20$ .

37. (New) The information recording medium according to claim 1, wherein the second material is represented by a composition formula:



38. (New) The information recording medium according to claim 1, wherein

in the first and second recording layers, a reversible phase change is caused by irradiation of the laser beam, and

a melting point of the second material is lower than that of the first material.

39. (New) The information recording medium according to claim 1, wherein in the first and second recording layers, a reversible phase change is caused by the irradiation of the laser beam, and the first information layer is disposed closer to a side from which the laser beam is incident than the second information layer.

40. (New) The information recording medium according to claim 1, wherein a thickness of the first recording layer is 9nm or less.

41. (New) The information recording medium according to claim 1, wherein a thickness of the second recording layer is in a range of 6nm to 15nm.

42. (New) The information recording medium according to claim 1, wherein a transmittance  $T_c$  (%) of the first information layer when the first recording layer is in a crystalline phase and a transmittance  $T_a$  (%) of the first information layer when the first recording layer is in an amorphous phase satisfy  $40 \leq (T_c + T_a)/2$  with respect to a laser beam having a wavelength in the range of 390nm to 430nm.

43. (New) The information recording medium according to claim 1, further comprising a separating layer disposed between the first information layer and the second information layer,

wherein the first information layer further comprises a first substrate, a first lower protective layer, a first upper protective layer, and a first reflective layer,

the second information layer further comprises a second lower protective layer, a second upper protective layer, a second reflective layer, and a second substrate, and

the first substrate, the first lower protective layer, the first recording layer, the first upper protective layer, the first reflective layer, the separating layer, the second lower protective layer, the second recording layer, the second upper protective layer, the second reflective layer, and the second substrate are disposed in this order from the side from which the laser beam is incident.

44. (New) The information recording medium according to claim 43, further comprising a transparent layer disposed between the first substrate and the first lower protective layer.

45. (New) The information recording medium according to claim 43, further comprising an interface layer disposed at at least one interface selected from the group consisting of an interface between the first lower protective layer and the first recording layer and an interface between the first upper protective layer and the first recording layer.

46. (New) The information recording medium according to claim 43, further comprising an interface disposed at at least one interface selected from the group consisting of an interface between the second lower protective layer and the second recording layer and an interface between the second upper protective layer and the second recording layer.
47. (New) The information recording medium according to claim 43, further comprising an interface layer disposed at at least one interface selected from the group consisting of an interface between the first upper protective layer and the first reflective layer and an interface between the second upper protective layer and the second reflective layer.
48. (New) The information recording medium according to claim 43, further comprising a transmittance adjusting layer for adjusting a transmittance of the first information layer between the first reflective layer and the separating layer.
49. (New) The information recording medium according to claim 48, further comprising an interface layer disposed between the first reflective layer and the transmittance adjusting layer.
50. (New) The information recording medium according to claim 43, wherein a thickness of the first substrate is in a range of 10 $\mu$ m to 800 $\mu$ m.

51. (New) The information recording medium according to claim 43, wherein a thickness of the second substrate is in a range of 400 $\mu$ m to 1300 $\mu$ m.

52. (New) The information recording medium according to claim 33, further comprising first and second electrodes, wherein

in the first and second recording layers, a reversible phase change is caused by the application of the current, and

the first recording layer, the second recording layer and the second electrode are laminated over the first electrode in this order.

53. (New) The information recording medium according to claim 52, further comprising an intermediate electrode disposed between the first recording layer and the second recording layer.

54. (New) A method for producing an information recording medium comprising a first information layer and a second information layer, the method comprising:

(a) forming the first information layer; and

(b) forming the second information layer,

wherein the first information layer comprises a first recording layer in which a reversible phase change is caused between a crystalline phase and an amorphous phase by irradiation of a laser beam or Joule heat generated by application of current,

the second information layer comprises a second recording layer in which a reversible phase change is caused between a crystalline phase and an amorphous phase

by the irradiation of the laser beam or the Joule heat generated by the application of the current,

the process (a) comprises forming the first recording layer with a base material containing Ge, Sb, and Te,

the process (b) comprises forming the second recording layer with a base material containing Sb and at least one element M1 selected from the group consisting of Ag, In, Ge, Sn, Se, Bi, Au, Mn and Te,

the first information layer is disposed closer to a side from which the laser beam is incident than the second information layer, and

wherein an separating layer is provided to distinguish the first recording layer and the second recording layer, the thickness of the separating layer is in the range of 1 $\mu$ m to 50 $\mu$ m.

55. (New) The method for producing an information recording medium according to claim 54, wherein the first and second recording layers are formed by sputtering using sputtering gas containing argon gas or krypton gas.

56. (New) The method for producing an information recording medium according to claim 55, wherein the sputtering gas further contains at least one gas selected from the group consisting of nitrogen gas and oxygen gas.

57. (New) The method for producing an information recording medium according to claim 55, wherein

a thickness of the first recording layer is 9nm or less, and

in the process (a), the first recording layer is formed at a film formation rate in a range of 0.1nm/sec to 3nm/sec.

58. (New) The method for producing an information recording medium according to claim 55, wherein

a thickness of the second recording layer is in a range of 6nm to 15nm, and

in the process (b), the second recording layer is formed at a film formation rate in a range of 0.3nm/sec. To 10nm/sec.

59. (New) The method for producing an information recording medium according to claim 54, wherein

the process (b) is performed before the process (a), and

after the process (b) and before the process (a), the method further comprises a process (c) of forming an separating layer over the second information layer, and

in the process (a), the first information layer is formed over the separating layer.

60. (New) A method for recording/reproducing an information recording medium, wherein

the information recording medium is the information recording medium according to claim 33,



with respect to the first information layer of the information recording medium,  
information is recorded/reproduced with a laser beam incident from a side of the first  
information layer,

with respect to the second information layer of the information recording medium,  
information is recorded/reproduced with the laser beam that has passed through the first  
information layer, and

a wavelength of the laser beam is in the range of 390nm or more and 430nm or  
less.

61. (New) The method for recording/reproducing an information recording medium  
according to claim 60, wherein

a linear velocity of the information recording medium when  
recording/reproducing information is in the range of 3m/sec. or more and 30m/sec. or  
less.

62. (New) The method for recording/reproducing an information recording medium  
according to claim 60, wherein

the laser beam is focused by an objective lens, and

a numerical aperture NA of the objective lens is in the range of 0.5 or more and  
1.1 or less.

63. (New) A method for recording/reproducing an information recording medium,  
wherein  
the information recording medium is the information recording medium according  
to claim 33,  
in the first and second recording layers of the information recording medium, a  
reversible phase change is caused between a crystalline phase and an amorphous phase  
by Joule heat generated by application of current, and  
an amplitude  $I_c$ , a pulse width  $t_c$ , an amplitude  $I_{a1}$ , a pulse width  $t_{a1}$ , an  
amplitude  $I_{a2}$  and a pulse width  $t_{a2}$  satisfy the relationships:  
 $I_c < I_{a2} < I_{a1}$  and  $t_{a1} \leq t_c$  or  $t_{a2} \leq t_c$ , wherein  
a current pulse with the amplitude  $I_c$  and the pulse width  $t_c$  is applied to the first  
or second recording layer to change the first or second recording layer from an  
amorphous phase to a crystalline phase,  
a current pulse with the amplitude  $I_{a1}$  and the pulse width  $t_{a1}$  is applied to the  
first recording layer to change the first recording layer from a crystalline phase to an  
amorphous phase, and  
a current pulse with the amplitude  $I_{a2}$  and the pulse width  $t_{a2}$  is applied to the  
second recording layer to change the second recording layer from a crystalline phase to  
an amorphous phase.